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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of)	Confirmation No. 7016
)	
ICHIMURA et al)	Examiner: JOHNSON, Connie P.
)	
Serial No.: 10/520,106)	Art Unit: 1752
)	
Filed: January 3, 2005)	

For: ACTIVE RAY SENSITIVE RESIN COMPOSITION, ACTIVE ENERGY RAY
SENSITIVE FILM AND METHOD FOR FORMING PATTERN USING THE FILM

AMENDMENT & RESPONSE TO OFFICE ACTION OF MARCH 8, 2007

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Please amend the captioned application as follows: